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(NGB.322)

AMENDMENTS TO THE CLAIMS:

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1. (Currently amended) An electrode for <u>a p-type</u> Group III nitride compound

semiconductor, comprising:

a film including a at least containing polycrystalline metal.

2. (Currently amended) An electrode for <u>a p-type</u> Group III nitride compound

semiconductor according to claim 1, wherein said polycrystalline metal comprises has

such a fiber structure in which that crystal planes of crystal grains are oriented.

3. (Currently amended) An electrode for <u>a p-type</u> Group III nitride compound

semiconductor according to claim 1, wherein said polycrystalline metal comprises has

large crystal grains.

4-6. (Canceled).

7. (New) The electrode according to claim 1, wherein the polycrystalline metal

comprises a fiber structure in which a crystal grain boundary density decreases such that a

quantity of defects in the metal/semiconductor boundary decreases.

8. (New) The electrode according to claim 2, wherein a percentage of oriented crystal

grains occupying said fiber structure is increased to provide an increase of an orientation

force of the metal film.

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9. (New) The electrode according to claim 2, wherein said fiber structure comprises a

predetermined percentage of oriented crystal grains to provide a predetermined

orientation force of the metal film.

10. (New) The electrode according to claim 1, wherein the polycrystalline metal

comprises a fiber structure including oriented crystal faces including closed packed

planes.

11. (New) An electrode for a p-type Group III nitride compound semiconductor, the

electrode comprising:

a polycrystalline metal film disposed on said p-type Group III nitride compound

semiconductor to form a metal/semiconductor boundary,

wherein said polycrystalline metal film comprises a fiber structure in which a

crystal grain boundary density decreases such that a quantity of defects in the

metal/semiconductor boundary decreases.

12. (New) The electrode according to claim 11, wherein said fiber structure of said

polycrystalline metal film comprises oriented crystal planes of crystal grains.

13. (New) The electrode according to claim 11, wherein said polycrystalline metal

comprises crystal grains of a predetermined large size.

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14. (New) The electrode according to claim 12, wherein a percentage of oriented

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crystal grains occupying said fiber structure is increased to provide an increase of an

orientation force of the metal film.

15. (New) The electrode according to claim 11, wherein the polycrystalline metal

comprises a fiber structure including oriented crystal faces including closed packed

planes.

16. (New) The electrode according to claim 11, wherein said p-type Group III nitride

compound semiconductor comprises one of GaN, AlGaN, and GaInN.

17. (New) The electrode according to claim 11, wherein said polycrystalline metal

comprises one of platinum (Pt), nickel (Ni, palladium (Pd), chromium (Cr), and iron (Fe).

18. (New) The electrode according to claim 11, wherein a degree of said crystal grains

of said predetermined large size is no less than a thickness of said polycrystalline metal

film.

19. (New) A p-type Group III nitride compound semiconductor light-emitting device,

comprising:

an electrode including a polycrystalline metal film disposed on a p-type Group III

nitride compound semiconductor layer of said light-emitting device to form a

metal/semiconductor boundary,

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wherein said polycrystalline metal film comprises a fiber structure in which a

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crystal grain boundary density decreases such that a quantity of defects in the

metal/semiconductor boundary decreases.

20. (New) The device according to claim 19, wherein said fiber structure of said

polycrystalline metal film comprises oriented crystal planes of crystal grains.

21. (New) The device according to claim 19, wherein said polycrystalline metal

comprises crystal grains of a predetermined large size.